Coupling Matrix-Based Design of Waveguide Filter Amplifiers

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Abstract—This paper extends the conventional coupling matrix theory for passive filters to the design of "filteramplifiers," which have both filtering and amplification functionality. For this approach, extra elements are added to the standard coupling matrix to represent the transistor. Based on the specification of the filter and small-signal parameters of the transistor, the active N + 3 coupling matrix for the "filteramplifier" can be synthesized. Adopting the active coupling matrix, the last resonator of the filter (adjacent to the transistor) and the coupling between them are modified mathematically to provide a Chebyshev response with amplification. Although the transistor has a complex impedance, it can be matched to the filter input by the choice of the coupling structure and the resonator frequency. This is particularly useful as the filter resonators can be of a different construction (e.g., waveguide) to the amplifier (e.g., microstrip). Here, an X-band filter-amplifier is implemented as an example, but the technique is general.

Index Terms—Active coupling matrix, amplifier, resonator, waveguide filter.

I. Introduction

MPLIFIERS are employed in, for example, communication systems to increase the incoming signal strength. The initial amplifier is ordinarily preceded by filtering to select desired bands of frequencies and reject others for channel selection and compliance. Combining the amplifier and the filter in a compact manner can improve performance, through removing intermediate impedance matching, but also in terms of component size and weight. High *Q*-factor waveguide-based components are of interest where the lowest loss is required, and they are widely employed in submillimetre-wave or terahertz applications. As active components become more commonplace at hundreds of gigahertz, where planar

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circuit losses are significant, the technology of choice for interconnects and filters is high-Q waveguides [1]–[3]. Waveguide components operating at more than 200 GHz have been demonstrated using such as a precision milling [4], SU-8 [5], and DRIE process [6] techniques. In addition, silicon micromachining techniques [7] and monolithic microwave integrated circuit (MMIC) membrane Schottky process [8] have been employed to realize millimeter-wave components that offer the potential for lithographically defined feature precision typical for MMICs.

In a waveguide amplifier design, connection to planar circuits often uses waveguide-to-planar circuit transitions [9]–[13]. Various forms of structures, including SIW [10], step ridges [11], antipodal finline arrays [12], and CPW lines [13], are employed as the interconnecting transition to the on-chip active components. However, the independent design of the transitions and the matching networks results in additional losses and circuit complexity. In this paper, we propose a combination of the matching network and transition into the (low loss) waveguide resonators of the adjoining filter, thereby minimizing losses. This approach also leads to a reduction in the overall size of the combined component.

Several filter-amplifier examples have been reported previously, some of which filters and the transistor are combined via impedance/admittance transformation referring to a common terminal impedance, based on the conventional 50 Ω matching condition; examples are in [14] and [15]. An equivalent $1/4 \lambda$ impedance transformer is employed to transform the impedance of the transistor in [14], and coupled lines are modeled according to the equivalent transmission line network to match the transistor in [15]. Compared with the waveguide codesign approach described here, the additional planar matching structure adds losses and circuit complexity. Another type of a filter-amplifier design approach uses the concept of actively coupled resonators or active impedance/admittance inverters to design the filter-amplifier [16]–[19]. There are also some examples of active microwave filters implementing negative resistance, which incorporates the active components into the resonators in [20]-[22]. However, these design approaches of the active filters usually need multiple active components to construct every active resonator or active inverter, and noise and nonlinear problems have to be investigated carefully. They are more likely applied in the planar amplifier circuits, because it becomes difficult to construct the active resonators or active inverters with 3-D waveguide structures. Some classical filteramplifier co-design examples are investigated in [23] and [24],

where the general N+2 (N is the order of the filter) coupling matrix is applied to design output matching filters of the power amplifiers. In [23], a tuning line is employed to eliminate the imaginary part of the transistor's output impedance; then, the filter design is completed by tuning the external couplings. In [24], the physical dimensions are not directly extracted from the matrix; instead, there is optimizing of the coupling structure and the center frequency of the resonator to achieve the filtering response. In our proposed design approach, a complete physical dimension synthesis is presented from a new N+3 matrix, offering appropriate good initial values and a complete design procedure.

This paper develops the N+3 coupling matrix for the first time, which allows the prediction of the filter-amplifier response including gain, since the transistor's parameters are included into the coupling matrix. A complete method to synthesize the matrix is given. We consider the transistor and the filter as one entity, and the N+3 active coupling matrix predicts the overall performance of the component characterized by scattering parameters. The matrix is then used to facilitate the full component design with the example of an X-band filter-amplifier.

This paper is organized as follows. In Section II, the novel active N+3 coupling matrix, including a transistor, is introduced. Section III describes the design and construction of an X-band filter-amplifier circuit demonstrator. Experimental results for the circuit are given in Section IV, after which conclusions and suggestions for further developments are summarized in Section V.

II. ACTIVE COUPLING MATRIX

A transistor is, in practice, a bilateral device, where the output load influences the input port impedance. Before deriving the active N+3 coupling matrix below, a simplified admittance network used to represent the transistor in small-signal operation is introduced in Fig. 1 [25].

The Y matrix describing the transistor is given by [25]

$$[Y_T] = \begin{bmatrix} Y_{gs} + Y_{gd} & -Y_{gd} \\ g_m - Y_{gd} & Y_{ds} + Y_{gd} \end{bmatrix}$$
 (1)

where Y_{gs} , Y_{gd} , and Y_{ds} are the admittances between the source, drain, and gate; g_m is the voltage-controlled current source representing the transconductance.

Fig. 2(a) shows a circuit of an Nth-order filter using lumped element representations of the resonators based on

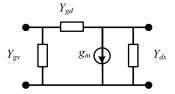


Fig. 1. Equivalent lumped circuit of a small-signal model for a transistor.

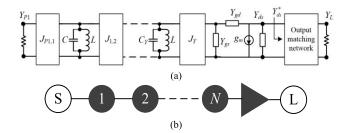


Fig. 2. Topology and equivalent lumped circuit for a coupled resonators filter-amplifier circuit. (a) Lumped circuit model. (b) Schematic of the circuit.

parallel capacitors and inductors coupled by J inverters. The load of the filter, in this case, is the transistor. The circuit shown in Fig. 2(a) is represented schematically in Fig. 2(b), where the resonators are represented by black filled circles and the clear circles denote the source and the load.

The input port admittance of the filter is denoted by Y_{P1} . The Nth resonator is directly coupled to the transistor by the inverter J_Y . A matching network is employed at the output to transfer the load Y_L to Y_{ds}^* , conjugately matched to the drainto-source admittance Y_{ds} . The load admittance Y_L represents the measurement port at the output, which is usually 50 Ω .

We recall that the aim of formulating this topology is to demonstrate a filter response with gain, and for our demonstrator, a Chebyshev response will be synthesized. Kirchoff's laws can be applied to the circuit in Fig. 2(a) to write down the equations at each circuit nodes. The resulting Y matrix is given in (2), shown at the bottom of this page. Following the matrix scaling process described in [26] and [27], this N+3 matrix [Y] in (2) can now be manipulated to derive matrix [A] shown in Fig. 3. This N+3 matrix has the rows and columns P_1 , P_2 , and P_3 for the filter's input, the transistor's input, and the load with matching, surrounding the conventional $N \times N$ general coupling matrix. The diagonal entries, $A_{P1,P1}$, $A_{P2,P2}$, and $A_{P3,P3}$ indicate the input admittance of the filter,

$$[Y] = \begin{bmatrix} Y_{P1} & -jJ_{P1,1} & 0 & \cdots & 0 & 0 & 0 \\ -jJ_{1,P1} & \left(\frac{1}{j\omega L} + j\omega C\right) & -jJ_{1,2} & \cdots & 0 & 0 & 0 \\ 0 & -jJ_{2,1} & \left(\frac{1}{j\omega L} + j\omega C\right) & \cdots & 0 & 0 & 0 \\ \vdots & \vdots & \vdots & \ddots & \vdots & \vdots & \vdots \\ 0 & 0 & 0 & \cdots & \left(\frac{1}{j\omega L} + j\omega C_Y\right) & -jJ_Y & 0 \\ 0 & 0 & 0 & \cdots & -jJ_Y & Y_{gs} + Y_{gd} & -Y_{gd} \\ 0 & 0 & 0 & \cdots & 0 & g_m - Y_{gd} & Y_{ds} + Y_{ds}^* + Y_{gd} \end{bmatrix}$$

$$(2)$$

$$P_{1} \rightarrow \begin{bmatrix} P_{1} & P_{2} & P_{3} \\ \hline Y_{P1} & -jm_{P1,1} & 0 & \cdots & 0 & 0 & 0 \\ -jm_{1,P1} & p & -jm_{1,2} & \cdots & 0 & 0 & 0 \\ 0 & -jm_{2,1} & p & \cdots & 0 & 0 & 0 \\ \cdots & \cdots & N \times N \text{ matrix} & \cdots & \cdots & \cdots \\ 0 & 0 & 0 & \cdots & p - jm_{n,n} & -jm_{n,P2} & 0 \\ 0 & 0 & 0 & \cdots & -jm_{P2,n} & \overline{Y}_{gs} + \overline{Y}_{gd} & -jm_{P2,P3} \\ P_{3} \rightarrow \begin{bmatrix} 0 & 0 & \cdots & 0 & -jm_{P3,P2} & \overline{Y}_{ds} + \overline{Y}_{ds}^{*} + \overline{Y}_{gd} \end{bmatrix}$$

Fig. 3. Matrix [A] showing the general $N \times N$ coupling matrix surrounded by extra columns and rows.

the input admittance of the transistor, and the transistor's load admittance with a matching network included.

Matrix [A], shown in Fig. 3, can be further decomposed into three matrices [28]

$$[A] = [T] + p \cdot [U] - j \cdot [m] \tag{3}$$

where the [T] matrix, expanded later in (14), includes the filter's port admittance, the input admittance of the transistor, and the load admittance. In (3), [U] is the identity matrix except for entries $U_{P1,P1}$, $U_{P2,P2}$, and $U_{P3,P3}$, which are zero. p is the complex frequency variable defined in [28] as

$$p = j \frac{1}{\text{FBW}} \left(\frac{\omega}{\omega_0} - \frac{\omega_0}{\omega} \right). \tag{4}$$

Here, FBW is the fractional bandwidth and ω_0 is the center frequency. The matrix [m] in (3) is the coupling matrix, of which $m_{i,j}$ denotes the interresonator coupling and $m_{Pk,i} = m_{i,Pk}$ are the coupling between ports and resonators (i = 1 to N; k = 1-3). The terms $m_{P2,P3}$ and $m_{P3,P2}$ are the couplings between the transistor's input and load. For the matrix [A], shown in Fig. 3, as the common factor -j is extracted as -i[m], the normalized coupling coefficients in the transistor become

$$m_{P2,P3} = \frac{\overline{Y}_{gd}}{i} \quad m_{P3,P2} = \frac{\overline{Y}_{gd} - \overline{g}_m}{i}.$$
 (5)

Compared with the general coupling matrix, three more entries of the [m] matrix are modified to achieve a Chebyshev input matching, namely the selfcoupling $m_{n,n}$, and the external couplings from the Nth resonator to the transistor, $m_{n,P2}$ and $m_{P2,n}$. The value of $m_{n,n}$, $m_{P2,n}$, and $m_{n,P2}$ are given by

$$m_{n,n} = -\frac{b}{a \cdot g_n g_{n+1}} \tag{6}$$

$$m_{n,n} = -\frac{b}{a \cdot g_n g_{n+1}}$$

$$m_{n,P2} = m_{P2,n} = \sqrt{\frac{a^2 + b^2}{a \cdot g_n g_{n+1}}}$$
(6)

where g_n and g_{n+1} are the standard g values that are defined and calculated in [28]. a and b are the normalized real and imaginary parts of the transistor's input admittance \overline{Y}_{in} and can be calculated from the transistor's Y matrix parameters

$$a = \operatorname{Re}\left\{\frac{\overline{Y}_{gd}[\overline{g}_m + \overline{Y}_{ds} + \overline{Y}_{ds}^*]}{\overline{Y}_{gd} + \overline{Y}_{ds} + \overline{Y}_{ds}^*} + \overline{Y}_{gs}\right\}$$
(8)

$$b = \operatorname{Im} \left\{ \frac{\overline{Y}_{gd} [\overline{g}_m + \overline{Y}_{ds} + \overline{Y}_{ds}^*]}{\overline{Y}_{gd} + \overline{Y}_{ds} + \overline{Y}_{ds}^*} + \overline{Y}_{gs} \right\}$$
(9)

$$\overline{Y}_{\text{in}} = a + jb. \tag{10}$$

Note that the term $jm_{n,n}$ visible at the bottom right corner of the $N \times N$ matrix shown within the red dotted line in Fig. 3 represents a frequency shift of the last resonator in the filter. This has been observed before for the case of transistors, mixers, and antennas, and is described in [29]. The shift in frequency is described by $m_{n,n}$ in (6), allowing the Chebyshev (or other) filtering response to be maintained independently of the nature of the complex input impedance of the transistor. This frequency shift can be positive or negative depending upon the imaginary part of the input admittance.

The following relationships can be used to calculate the S-parameters for the complete circuit [26], [28], [30]:

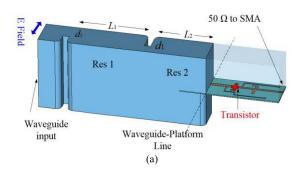
$$S_{11} = 2[A]_{P1,P1}^{-1} - 1 (11)$$

$$S_{21} = 2\sqrt{\text{Re}(\overline{Y}_{ds}^*)}[A]_{P3,P1}^{-1}.$$
 (12)

III. FILTER-AMPLIFIER DESIGN USING COUPLING MATRIX APPROACH

In this section, the design procedure and simulation results for an X-band rectangular waveguide filter-amplifier are described. Before discussing the design procedure, it is informative to illustrate the completed filter-amplifier component, which is shown in Fig. 4.

Port 1 is assigned to the waveguide port, and Port 2 refers to the $50-\Omega$ microstrip output port. As shown in Fig. 4, the two-pole waveguide filter is comprised of Resonator 1 and Resonator 2, which are waveguide TE101 cavities coupled via asymmetrical capacitive irises. Resonator 2 is formed by a waveguide cavity and the transistor coupling probe, interconnecting transmission line and the transistor. A reduced height section of the waveguide forms a platform on which the microstrip substrate is located. The substrate has the probe and



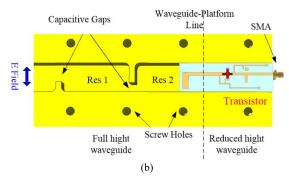


Fig. 4. Layout of the waveguide filter-amplifier. (a) 3-D view of the internal waveguide and the microstrip circuit. (b) Sectional view of the filter and platform for the transistor circuit.

transmission line, and also the transistor with bias connections placed on it.

A. Circuit Response Calculation Using the Coupling Matrix

The values of the coupling coefficients are given by the standard expressions for the desired filter response except for the couplings $m_{n,n}$, $m_{P2,n}$, and $m_{n,P2}$. The filter and transistor specifications can be translated into elements of the N+3coupling matrix in Fig. 3 using standard tables or formulas [27], [28]. Here, we will use an example of a two-pole Chebyshev filter with a center frequency f_0 of 10 GHz, a bandwidth of 500 MHz [fractional bandwidth (FBW) = 0.05], and a passband return loss of 20 dB. The transistor used is an NE310S01 with unnormalized parameters Y and normalized parameters \overline{Y} (i.e., scaled by $Y_0 = 0.02$ S) summarized in Table I [25], [31]. It should be noted that the Y matrix parameters employed here are calculated assuming that the transistor operates at 10-GHz center frequency, and the operating conditions of the transistor are drain-to-source voltage $V_{ds} = 2$ V and drain current $I_{ds} = 10$ mA.

Based on the prototype Chebyshev low-pass filter and the normalized transistor's Y matrix parameters, the active coupling matrix [m] can be calculated according to (6), (8), and (9) to give (13), shown at the bottom of this page.

TABLE I VALUES OF THE TRANSISTOR'S Y MATRIX PARAMETERS

Y parameters	Values	Normalized \overline{Y} parameters	Values
g_m	0.0696- 0.1350j	\overline{g}_m	3.4812-6.7500j
Y_{gd}	0.0003+0.0033j	\overline{Y}_{gd}	0.0164+0.1629 <i>j</i>
Y_{ds}	0.0055+ 0.0127 <i>j</i>	\overline{Y}_{ds}	0.2752+ 0.6367 <i>j</i>
Y_{gs}	0.0051+ 0.0276 <i>j</i>	\overline{Y}_{gs}	0.2528+ 1.3799 <i>j</i>

All parameters are calculated from the data sheet as the transistor operating at 10 GHz.

This coupling matrix is asymmetric because of the active element. The matrix [T], used to describe the filter ports admittance and the transistor's input and output, is given by

Using (11) and (12), the resultant scattering parameters can be calculated from the active coupling matrix and are presented in Fig. 5(a). The novel active coupling matrix produces a standard Chebyshev response with amplification.

As well as the coupling matrix response, Fig. 5(b) shows the response from an ADS circuit simulation [in Fig. 5(c)] using the full frequency variation of the input impedance of the transistor and the constant $Y_{\rm in}$. As can be seen, the agreement is good, showing in the case that approximating $Y_{\rm in}$ as a constant has a little effect.

B. Physical Design of the Waveguide Filter-Amplifier

The coupling matrix in Section III-A was based on normalized admittance parameters, and assumed that the normalized admittance stayed consistent from the input to output; this works well and results in good prediction of the circuit response as shown in Fig. 5(a). Matrix [A] scaled from admittance matrix [Y] enables us to ignore the matching and admittance conditions and to concern ourselves with just the coupling coefficients in the coupling matrix [m]. That is, the fact that the coupling matrix of Fig. 3 is derived assuming a consistent normalized admittance does not matter, and it can be used with, for example, the waveguide and the microstrip without reference to their admittance. This is exactly the same

$$[m] = \begin{bmatrix} 0 & 1.2264 & 0 & 0 & 0\\ 1.2264 & 0 & 1.6621 & 0 & 0\\ 0 & 1.6621 & -1.0762 & 2.3407 & 0\\ 0 & 0 & 2.3407 & 0 & 0.1629 - 0.0164j\\ 0 & 0 & 0 & 6.9129 + 3.46578j & 0 \end{bmatrix}$$
(13)

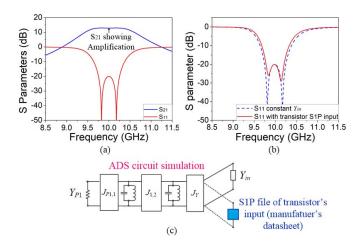


Fig. 5. (a) Calculated filter-amplifier response using the coupling matrix formulation. (b) Comparison of the S-parameters response of circuit simulation using constant $Y_{\rm in}$ and the full frequency variation of the input impedance of the transistor. (c) Circuit schematic in ADS.

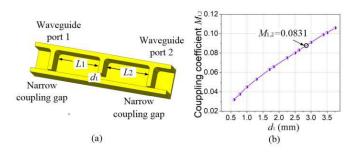


Fig. 6. Coupled waveguide cavities and the process to extract the coupling coefficients. (a) Structure to determine the physical dimension of the coupling aperture. (b) Coupling coefficients versus dimension d_1 . All points are at 10 GHz.

as in conventional filter design using the coupling matrix and is one of its great strengths.

Hence, in practice, the geometries of the coupling gaps in the input waveguide filter and the physical structure of the transition from the waveguide to the microstrip input of the transistor can be determined from the coupling matrix [m] in (13). The process and equations follow closely from just a simple filter [28], and this is discussed in the Appendix. The design process is discussed below.

The first step is to determine the interresonator coupling strength. As with just a conventional simple filter, the coupling coefficient $m_{1,2} = m_{2,1}$ between the two resonators is scaled by the FBW from the coupling matrix [m] in (13)

$$M_{1,2} = \text{FBW} \cdot m_{1,2} \quad M_{2,1} = \text{FBW} \cdot m_{2,1}.$$
 (15)

For this example, $M_{1,2} = 0.0831$. The coupling coefficients can be realized by a suitable gap in the wall between waveguide resonators. A pair of waveguide-coupled resonators, shown in Fig. 6(a), are simulated in a full-wave simulator; CST was used here. This is in order to find the target coupling coefficient $M_{1,2}$ [28]. There is weak coupling to the input and output via a narrow capacitive gap, as shown in Fig. 6(a). The coupling coefficient $M_{1,2}$ between the two resonators can be altered by varying the iris gap d_1 . A graph

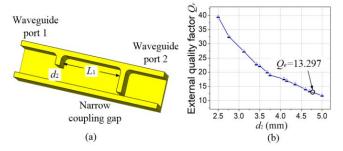


Fig. 7. Waveguide structure to extract the quality factor for Resonator 1. (a) Structure to determine physical dimension for waveguide cavity with the quality factor. (b) External quality factors Q_e versus dimension d_2 . All points are at 10 GHz.

of the coupling coefficient $M_{1,2}$, as shown in Fig. 6(b), can be plotted [28]. The coupling coefficient given in (15) can now be located and is shown in Fig. 6(b), and hence, a d_1 of 2.85 mm can be found.

The next step is to determine the iris size at port 1 of the waveguide filter. This can be done by extracting the external quality factor of Resonator 1 (Q_{e1}). In the N+3 coupling matrix, Q_{e1} is related to the external couplings

$$Q_{e1} = \frac{1}{\text{FBW} \cdot m_{1,P1}^2} = \frac{1}{\text{FBW} \cdot m_{P1,1}^2}, \quad m_{P1,1} = m_{1,P1}. \quad (16)$$

From (13) and (16), it is found that the external quality factor required is $Q_{e1}=13.297$. Fig. 7 shows the setup for determining Q_{e1} , i.e., the quality factor at the input to the waveguide filter. The S-parameter response, generated by simulating the single-waveguide resonator in Fig. 7(a), is a single resonance curve, and Q_{e1} is extracted by calculating its quality factor. Changing the iris length d_2 alters the values of Q_{e1} , and this is shown in Fig. 7(b). As shown in the graph, for example, we can find a value of $d_2=4.85$ mm for the input iris to the filter. Note that both the interresonator coupling [see Fig. 6(b)] and the external quality factor [see Fig. 7(b)] are evaluated at 10 GHz, the center frequency of the filteramplifier.

Now, we need to consider the connection to the transistor via Resonator 2, as shown in Fig. 4. This comprises a combination of the waveguide cavity and planar circuit elements including the transistor itself. This is depicted in Fig. 8(a). Through an *E*-field probe, Resonator 2 is directly coupled to the transistor's input, which is a complex value impedance.

The coupling strength from the resonator to the transistor is related to $m_{P2,2} = m_{2,P2} = 2.3407$, and the selfcoupling $m_{2,2} = -1.0762$ related to the center frequency of Resonator 2, and all these couplings can be achieved by constructing appropriate geometries of the structure shown in Fig. 8(a). The external coupling $m_{P2,2} = m_{2,P2}$ mainly depends on the coupling structure, that is, the probe length (l) and the interconnecting transition length (s). The selfcoupling $m_{2,2}$ mainly depends upon the length of Resonator 2 (L_2) .

The next step is to determine the values of l, s, and L_2 that fulfill the required external couplings and selfcoupling in (13). However, the physical dimensions corresponding

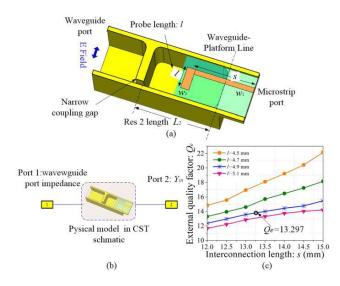


Fig. 8. Setup to extract the external quality factor for Resonator 2 incorporating the transistor's input. (a) Structure for extracting the eternal quality factor of Resonator 2 interconnecting the input of the transistor. (b) Q_{eT} extraction setup in CST. (c) External quality factor Q_e versus interconnection length s. All points are at 10 GHz.

 $m_{P2,2} = m_{2,P2}$ cannot be extracted directly as for the waveguide case in Fig. 7. Instead, the $m_{P2,2} = m_{2,P2}$ and $m_{2,2}$ can be evaluated by the S-parameter response of the combined structure of Resonator 2 incorporating the probe and input of the transistor.

In the practical design, the external coupling $m_{P2,2} = m_{2,P2}$ and selfcoupling $m_{2,2}$ can be determined by extracting the external quality factor (Q_{eT}) and the resonant frequency (f_T) of Resonator 2 incorporating the input of the transistor. The derivations of the frequency (f_T) and quality factor (Q_{eT}) are given in the Appendix, and f_T and Q_{eT} can be calculated using the external coupling $m_{P2,n} = m_{n,P2}$ and selfcoupling $m_{n,n}$. Significantly, the Appendix also shows that $f_T = f_0$ and $Q_{eT} = Q_{e1}$, and this fact now allows the design procedure to continue in exactly the same way as for a conventional filter, that is, the same as for the above-described input port.

The whole structure includes the resonator itself and the complex input impedance of the transistor, as well as the transition from the waveguide to the microstrip. This mixed resonator-microstrip construction can be simulated in CST, and the appropriate dimensions are found to fulfill the requirement of, in this case, $Q_{eT}=13.297$ at the center frequency $f_T=10$ GHz.

The simulation of the single resonator, as shown in Fig. 8(b), was performed in CST, and a resonance frequency and the external quality factor are determined. As the setup schematically depicts in Fig. 8(b), the microstrip port is connected to port 2 in CST, with Port 2 load set to be the input impedance of the transistor. Port 1 is set to be the value of waveguide impedance; then, the whole structure is simulated. The microstrip circuit in Fig. 8(a) is modeled using the RT/5870 substrate with a thickness of 0.254 mm and a relative dielectric constant $\varepsilon_r = 2.33$. The center frequency is mainly determined by the length of the resonator (L_2), the length of

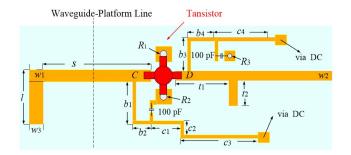


Fig. 9. Layout of the microstrip transistor part. Length t_2 is a single-stub matching for the output of the transistor to the 50- Ω transmission line.

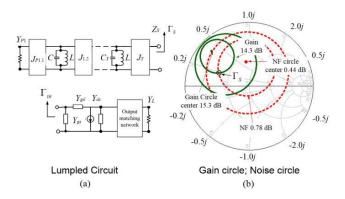


Fig. 10. Circuit design for the transistor amplifier. (a) Equivalent lumped circuit of the matching filter. (b) Constant-gain and constant-noise figure circles.

the E-field probe (l), and the length of the feed transmission line (s). In the simulation, the width of the feed line and probe (w_1, w_3) are kept constant, and only the dimensions of l and s are changed. During this tuning process, L_2 is adjusted to keep the center frequency at 10 GHz. The simulation results are shown in Fig. 8(c) from which the appropriate lengths of L_2 , l, and s can be chosen to achieve the target $Q_{eT} = 13.297$.

To complete the discussion, here, we briefly introduce the microstrip transistor circuit design. The microstrip part of the device consists of the probe, feed transmission line, transistor, bias circuits, and output matching stub. The output matching network is assumed to conjugately match to Y_{ds} as shown in Fig. 2(a). The characteristic impedance of the output transmission line of width w_2 is 50 Ω . The lengths of t_1 and t_2 are found using the single-stub matching method in [25]. The lengths $b_1 + b_2$ and $b_3 + b_4$ are quarter-wavelength long bias tees at 10-GHz center frequency and are connected to the via-ground holes through 100-pF surface mount capacitors. Square pads are located at the end of the bias tees to connect the dc power. The ground of the PCB is connected to the base of the platform by pressure. The simulated operating conditions of the transistor are drain-to-source voltage $V_{ds} = 2$ V and drain current $I_{ds} = 10$ mA [31]. The layout of the microstrip circuit is shown in Fig. 9.

The simulated noise performance for the matched amplifier is shown in Fig. 10. In the Smith chart [see Fig. 10(b)], the impedance synthesized at the transistor input port is superimposed over the device noise and gain contours. The reflection

TABLE II Values of Initial and Normalized Filter-Amplifier Parameters

	Initial	Optimized		Initial	Optimized
	(mm)	(mm)		(mm)	(mm)
$\overline{L_1}$	23.00	23.76	w	1.2	1.2
L_2	17.80	18.71	b_1	2.96	2.96
d_1	2.85	3.22	b_2	1.33	1.33
d_2	4.85	5.39	b_3	2.50	2.50
l	4.9	4.83	b_4	2.00	2.00
S	13.30	12.99	c_1	1.50	1.50
R_1	0.30	0.30	c_2	1.10	1.10
R_2	0.30	0.30	C_3	5.00	5.00
R_3	0.30	0.30	c_4	5.00	5.00
w_1	1.20	1.20	t_1	3.22	3.22
w_2	0.72	0.72	t_2	3.18	3.18
w_3	2.00	2.00			

coefficient looking into the source Γ_S [see Fig. 10(a)] has been calculated [28] and is shown on the Smith chart [see Fig. 10(b)], where 14.3-dB gain circle and 0.78-dB noise figure circle intersect. Recalling the aim of our work is to demonstrate the filter-amplifier with the Chebyshev response using the N+3 coupling matrix, and this noise figure has not been further optimized.

All the parameters necessary to form the filter-amplifier have been determined as discussed above. Therefore, the complete component can be simulated. The microstrip part, including the transistor model, is simulated in ADS to generate an S2P. Then, this cosimulation is combined in CST with the waveguide model and microstrip part for the complete filter-amplifier structure. The parameters used for the simulations are given in Table II and are the same as the values shown in the design graphs in Figs. 6(b), 7(b), and 8(c). Table II shows the initial values and optimized values. Optimization goals, in this case, are set to be: from 9.75 to 10.25 GHz, S_{11} is under -20 dB; from 9.75 to 10.25 GHz, S_{22} is under -10 dB; and critical points 9.824 and 10.178 GHz are under -40 dB.

Both the initial response and an optimized response, using the sizes specified in Table II, are shown in Fig. 11. The optimized results in Fig. 11(a) and (b) show that over the passband, S_{11} is below -20 dB, S_{21} shows gain around 13 dB, and S_{22} is below -10 dB. The good correlation between the initial and optimized responses demonstrates the validity of the coupling matrix technique in providing starting values for the waveguide filter-amplifier design process. Fig. 11(c) shows a noise figure (NF), which is about 1.10 dB over the passband, and the minimum NF for the device is 1.02 dB at 9.85 GHz. The real and imaginary parts of the input impedance of the transistor are shown in Fig. 11(d).

IV. FABRICATION AND MEASUREMENTS

The waveguide structure is made in two halves cut along the *E*-plane and is machined from aluminum (AL5083) on a CNC machine. The microstrip circuit is fabricated on the 0.254-mm thickness RT/5870 substrate. Fig. 12 shows a photograph of the device.

The measurement is performed using an Agilent PNA E8362B vector network analyzer referenced to the input

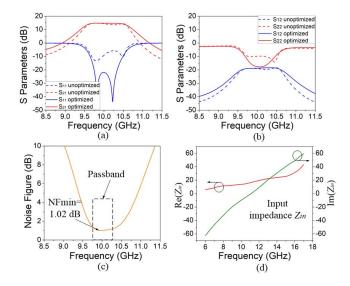


Fig. 11. Cosimulation results of the waveguide filter integrated with the amplifier. (a) Scattering parameters S_{11} and S_{21} . (b) Scattering parameters S_{22} and S_{12} . (c) Noise figure. (d) Input impedance of the transistor.

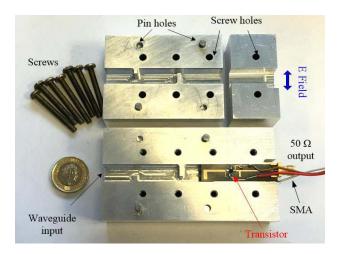


Fig. 12. Photograph for the fabricated device.

and output ports. As the picture in Fig. 13(a) shows, the input waveguide flange is connected to port 1 using a WR-90 coaxial-to-waveguide adapter with losses <0.1 dB. The setup is calibrated with coaxial standards without the adaptor. Thus, the measurements do include the tiny effect of the coaxial cable-to-waveguide adapter. The 50- Ω microstrip output is connected to port 2 of the analyzer through an SMA connector. Bias condition of the transistor is provided by a gate-to-source voltage of $V_{gs} = -0.52$ V and drain-to-source voltage of $V_{ds} = 2.2$ V. The measured S-parameters response is compared with the simulated one in Fig. 13(b) and (c) and displays a good agreement with the two-pole Chebyshev filtering characteristic and also a gain. The measured in-band small-signal gain is within 11.7 ± 0.46 dB from 9.75 to 10.25 GHz. The measured input and output return losses are around 13.8 and 10.62 dB, respectively, over the passband. The disagreement may be caused by the fabrication tolerances and any deviation of the transistor parameters from its data sheet. The 1-dB compression point examined at 10 GHz is about -2.9 dBm as shown in Fig. 13(d).

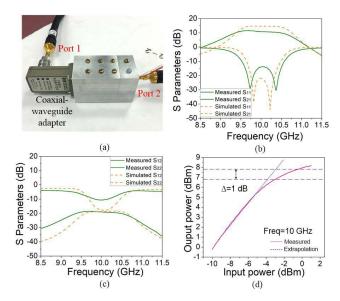


Fig. 13. Circuit simulation and measurement results. (a) Measurement setup. (b) Scattering parameters S_{11} and S_{21} . (c) Scattering parameters S_{22} and S_{12} . (d) P_1 dB measurement.

V. CONCLUSION

This paper described a novel active coupling matrix with transistor parameters included; it is used to synthesize a specified filter response including gain. The extended N+3 active coupling matrix builds on the general N+2 coupling matrix formulation. The resulting N+3 active coupling matrix can be used to generate the necessary matrix elements from which circuit optimization is performed. This allows the prediction of the response for the filter-amplifier and provides the initial values of the waveguide filter structure. Semiempirical simulation trials can be used to realize the physical geometries corresponding to the matrix values for a given circuit technology. Further applications of matching a complex port through the resonator circuit can be generalized to other components, e.g., mixers, antennas, and so on.

The topology proposed here makes it possible to extend this methodology to amplifier circuits resonator matched both at the input and output ports. Although in this example only input resonators matching circuits are employed, this approach is currently being extended for matrix descriptions, which incorporate both input, interstage, and output resonators matching, for multistage amplifiers.

For conventional filters, although the coupling matrix is essentially a narrowband approach, good use is made of the technique even when the filter bandwidths become larger. The matrix only needs to give a good estimate for the physical dimensions, so the final optimization is possible. Of course, this filter-amplifier co-design approach can be generalized to wideband amplifiers design by introducing a frequency-variant model of the transistor, but this is not possible with the current coupling matrix.

For this demonstrator, a microstrip circuit containing the transistor is combined with a WR-90 rectangular waveguide. Combining the filter design with the active element can allow for more compact components. Elements of the matching network have been transferred to waveguide resonators,

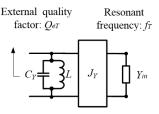


Fig. 14. Equivalent lumped circuit the *N*th resonator coupled to the input admittance of the transistor.

shrinking the overall size of the device and also increasing the port-to-port isolation. It is also noted that waveguide high-Q filter structures can be employed to offer lower loss impedance matching/filtering functions to the active devices. This latter effect will become more significant as the operating frequency, and therefore, planar circuit losses increase.

APPENDIX

Here, we calculate the center frequency f_T and the external quality factor Q_{eT} of the last resonator in the filter when it is connected to the transistor input.

The equivalent lumped circuit of the Nth resonator coupled to the input admittance of the transistor (Y_{in}) is shown in Fig. 14. The input admittance of the transistor Y_{in} , which is a complex value, is coupled through the inverter J_Y . Referring [26] and [27], the capacitor C_Y and the inverter J_Y can be expressed in terms of selfcoupling $m_{n,n}$ and external couplings $m_{P2,n} = m_{n,P2}$ by

$$C_Y = C(1 - \text{FBW} \cdot m_{n,n})$$

$$J_Y = \sqrt{\text{FBW}\omega_0 C \cdot Y_0} \cdot m_{n,P2} = \sqrt{\text{FBW}\omega_0 C \cdot Y_0} \cdot m_{P2,n}$$
(18)

where C is the capacitance of the first to the (N-1)th resonators in Fig. 2. The value of transistor's admittance Y_{in} is given by

$$Y_{\rm in} = (a+jb) \cdot Y_0. \tag{19}$$

The input admittance of the circuit in Fig. 14 can now be calculated and compared with the standard equation for the admittance of a loaded resonant circuit. The input admittance (Y_{res}) of the Nth resonator incorporating Y_{in} can be expressed as

$$Y_{\text{res}} = j\omega C_Y + \frac{1}{j\omega L} + \frac{J_Y^2}{Y_{\text{in}}}.$$
 (20)

Substitute (17)–(19) into (20), we have

$$Y_{\text{res}} = j\omega C \left(1 - \text{FBW} \cdot m_{n,n} - \frac{b \cdot \text{FBW}\omega_0 \cdot m_{P2,n}^2}{(a^2 + b^2) \cdot \omega} \right) + \frac{1}{j\omega L} + \frac{a \cdot \text{FBW}\omega_0 C \cdot m_{P2,n}^2}{(a^2 + b^2)}. \quad (21)$$

At the center frequency (ω_T) , where for the narrowband approximation $(\omega = \omega_T)$, Y_{res} satisfies

$$Im(Y_{res})|_{\omega=\omega_T} = 0. (22)$$

Substitute (21) into (22), yielding

$$\left(\frac{\omega_0}{\omega_T}\right)^2 + \frac{b \cdot \text{FBW} \cdot m_{P2,n}^2}{(a^2 + b^2)} \left(\frac{\omega_0}{\omega_T}\right) - (1 - \text{FBW} \cdot m_{n,n}) = 0.$$
(23)

Then, (23) can be solved to give

$$\left(\frac{\omega_{0}}{\omega_{T}}\right) = \frac{-\frac{b \cdot \text{FBW} \cdot m_{p_{2,n}}^{2}}{(a^{2} + b^{2})} \pm \sqrt{\left(\frac{b \cdot \text{FBW} \cdot m_{p_{2,n}}^{2}}{(a^{2} + b^{2})}\right)^{2} + 4(1 - \text{FBW} \cdot m_{n,n})}}{2}.$$
(24)

Because the ratio of ω_T and ω_0 should be positive, only the positive root is used. Substituting $\omega_T = 2\pi f_T$ and $\omega_0 = 2\pi f_0$ into (24), the center frequency f_T can be calculated as

$$f_T = \frac{2(a^2 + b^2) \cdot f_0}{b \cdot \text{FBW} \cdot m_{n,P2}^2 \left(\sqrt{1 + \frac{4(1 - m_{n,n} \cdot \text{FBW})(a^2 + b^2)^2}{b^2 \cdot m_{n,P2}^4 \cdot \text{FBW}^2}} - 1\right)}.$$
(25)

As the admittance Y_{res} is given in (21), the external quality factor Q_{eT} can be calculated by [28]

$$Q_{eT} = \frac{f_T}{f_0} \left(\frac{(a^2 + b^2)}{a \cdot \text{FBW} m_{P2,n}^2} - \frac{m_{n,n} \cdot (a^2 + b^2)}{a \cdot m_{P2,n}^2} \right) - \frac{b}{a}.$$
 (26)

It is interesting to substitute $m_{P2,2} = m_{2,P2} = 2.3407$ and $m_{2,2} = -1.0762$ in the coupling matrix (13) into (25) and (26); the external Q of Resonator 2 coupled with Y_{in} can be calculated to give $Q_{eT} = 13.297$, and the resonant frequency is calculated as $f_T = 10$ GHz.

Now, recalling $m_{P2,n} = m_{n,P2}$ and $m_{n,n}$, which are defined in (6) and (7), the final step is to substitute (6) and (7) into (25) and (26), respectively, to give the simple solutions

$$f_T = f_0 \tag{27}$$

$$f_T = f_0$$
 (27)
 $Q_{eT} = \frac{g_n g_{n+1}}{\text{FBW}} = Q_{e1}.$ (28)

It can be seen from (27) and (28) that the external Q and center frequency of the resonator coupled with the active component are the same as the case for conventional filters [28]. That is, $Q_{eT} = Q_{e1}$ even though the load is complex. This fact allows the method of designing the filter-amplifiers to much more closely resemble the design of a standard filter [28].

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